

Vita

The author was born in Shanghai, China, on September 4, 1966. He received the B.S. degree from Fudan University, Shanghai, China, in 1989, and the M.S. degree from Virginia Polytechnic Institute and State University, Blacksburg, VA, in 1992, both in physics. From 1989 to 1990 he was employed as an engineer at the Nondestructive Testing Center of the Shanghai Nonferrous Corporation, Shanghai, China. Since 1992 he has been working towards the Ph.D. degree at the Bradley Department of Electrical Engineering, Virginia Polytechnic Institute and State University. His research interests include low-voltage applications, high-density power supply designs, thermal and EMI analysis, soft-switching and power-factor-correction techniques. The author is a student member of IEEE Power Electronics Society.